LONG TERM PERFORMANCES OF NON-EVAPORABLE GETTER FILMS IN THE LARGE HADRON COLLIDER

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Abstract

To provide Ultra High Vacuum conditions in the Long Straight Sections (LSS) of the Large Hadron Collider (LHC) the internal surface of the room temperature sectors is coated with a Non-Evaporable Getter thin film. This material is highly reactive, thus when a molecule impinges on its surface it is firstly chemically trapped and then desorbed into the bulk of the material itself. If the gas load on the surface is too high the NEG surface is saturated, having no more free site to host the impinging molecules. In order to restore its pumping properties the oxide layer formed on the surface has to be removed. For this reason the NEG material is heated allowing the diffusion of the oxide layer into the bulk: this process is called activation.

In 2013, the LHC operation was stopped for a 20 months period called Long Shutdown 1 in order to allow consolidation, maintenance and upgrade. During this period about 80% of the room temperature NEG coated sectors were vented, baked and then re-activated. This study was focused on the analysis of the vacuum performances of this NEG thin film when subjected to a considerable number of venting and activation cycles. The first step of this study was to collect and analyse the ultimate pressure values on all the sectors of the LHC after each venting and activation cycle.

In parallel an experimental study was carried out in laboratory. Here fifteen venting and activation cycles were performed on a NEG coated chamber in order to determine the evolution of the pumping speed, transmission factor and capture probability. Finally the data collected in the LHC and the experimental results were matched in order to explain the measured ultimate pressure trend in the machine and foresee the vacuum performances in the next twenty years of operations of the LHC accelerator.
Chapter 1 introduces the CERN accelerator complex, the LHC machine and more in detail the Long Straight Sections, where NEG materials are employed.

In Chapter 2 all the quantities, the instruments and the tool used for this study are presented and described, giving basic notions of vacuum physics and technology.

Chapter 3 is focused on the description of NEG materials, on their general properties and on the parameters affecting their performances.

The Long Shutdown 1 and so the main purposes of this study are presented in Chapter 4; here an analysis of the ultimate pressures in the LHC is carried out.

Chapters 5 and 6 are dedicated to the description of the experimental techniques employed for this study and of the obtained results.

Finally in Chapter 7 is presented a summary of the conclusions.
Sommario

Per raggiungere le condizioni di Ultra High Vacuum (UHV) nelle Long Straight Sections (LSS) del Large Hadron Collider le superfici interne dei settori a temperatura ambiente vengono rivestite con un film sottile di materiale appartenente all categoria dei Non-Evaporable Getter (NEG). Quando una molecola impatta sulla superficie di un NEG, essa viene intrappolata, grazie all’alta reattività chimica di questi materiali, e poi diffusa all’interno del bulk. Se la superficie reattiva viene esposta alla pressione atmosferica o a una pressione troppo alta essa viene istantaneamente saturata, riempiendo tutti i siti liberi di reazione e annullando le proprietà di pompaggio. Per ristabilire le proprietà di assorbimento è necessario che il layer di ossido formato sulla superficie sia rimosso. Per questa ragione il NEG viene riscaldato a una temperatura sufficiente da permettere la diffusione dello strato di ossido all’interno del bulk: questo processo è chiamato attivazione.

Questo studio si pone come scopo quello analizzare l’evoluzione delle prestazioni dei NEG thin films, quando sottoposti a un numero consistente di cicli di venting e attivazione. Nel 2013 le operazioni in LHC sono state interrotte per un periodo di venti mesi chiamato Long Shutdown 1, per sottoporre la macchina a interventi di manutenzione e aggiornamento. Durante questo periodo circa l’80% dei settori a temperatura ambiente, rivestiti da film di NEG, sono stati ventilati per consentire gli interventi, richiedendo quindi una nuova attivazione. Nella prima fase di questo studio i valori di pressione misurati in tutti i settori di LHC dopo ogni ciclo di attivazione sono stati raccolti e analizzati. Questa fase di analisi è stata affiancata da uno studio sperimentale. In questo ambito una camera rivestita da un film NEG è stata sottoposta a quindici cicli di venting e attivazione per studiare l’evoluzione della velocità’
di pompaggio, dei valori di trasmissione e della \textit{capture probability}. Nella fase finale, combinando i dati ottenuti in laboratorio con quelli raccolti in LHC, è stato possibile comprendere il comportamento delle pressioni nella macchina e dunque fare una stima sull’evoluzione delle prestazioni del sistema a vuoto dell’LHC negli anni a venire. Il Capitolo 1 da’ una panoramica sul CERN, sugli acceleratori che ospita e in particolare sull’LHC e le LSS, che assumono un ruolo centrale in questo studio.

Nel Capitolo 2 vengono introdotte le nozioni fondamentali di fisica e tecnologia del vuoto, dando una posizione di rilievo alla descrizione delle grandezze e degli strumenti utilizzati.

Il Capitolo 3 è integralmente dedicato ai materiali NEG partendo dalla definizione delle grandezze che li caratterizzano fino ad arrivare alla descrizione dei parametri che ne influenzano le caratteristiche.

Il Long Shutdown 1 e l’analisi delle pressioni in LHC vengono trattate dettagliatamente nel Capitolo 4.

Nel Capitolo 5 e 6 vengono presentati le tecniche e i materiali utilizzati per l’analisi sperimentale e i risultati da essa derivati.

Infine nel Capitolo 7 sono raccolte le conclusioni di questo studio.
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Chapter 1

CERN

1.1 CERN accelerator complex

The accelerator complex at CERN is a succession of machines that accelerate particles to increasingly higher energies. Each machine boosts the energy of a beam of particles, before injecting it into the next machine in the sequence. In the Large Hadron Collider (LHC, 27 km long), the last element in this chain, particles are accelerated up to the record energy of 7 TeV per beam. Most of the other accelerators in the chain have their own experimental halls where beams are used for experiments at lower energies. The source protons are produced by a simple bottle of hydrogen gas. An electric field is used to strip hydrogen atoms of their electrons to yield protons. Linac 2, the first accelerator in the chain, linearly accelerates the protons to the energy of 50 MeV. The beam is then injected into the 157 meters long Proton Synchrotron Booster (PSB), which accelerates the protons to 1.4 GeV, followed by the Proton Synchrotron (PS, 628 meters long), which pushes the beam to 25 GeV. Protons are then sent to the Super Proton Synchrotron (SPS, 7 km long) where they are accelerated to 450 GeV. The protons are finally transferred to the two beam pipes of the LHC. The beam in one pipe circulates clockwise while the beam in the other pipe circulates anticlockwise. It takes 4 minutes and 20 seconds to fill each LHC ring, and 20 minutes for the protons to reach their maximum energy of 7 TeV. Beams circulate for many hours inside the LHC beam pipes under normal operating conditions. The two beams
are brought into collision inside four detectors (ALICE, ATLAS, CMS and LHCb) where the total energy at the collision point is equal to 14 TeV. [1].

### 1.2 The Large Hadron Collider

The Large Hadron Collider (LHC) is the world’s largest and most powerful particle accelerator. It first started up on 10 September 2008, and remains the latest addition to CERN’s accelerator complex. The LHC consists of a 27 km ring of superconducting magnets with a number of accelerating structures to boost the energy of the particles along the way. The beams are kept into their orbit by strong magnetic field provided by superconducting magnets. To reach superconductivity regime the magnets are cooled down to the temperature of 1.9 K. To achieve this temperature the superconducting parts of the accelerator are connected to a liquid helium distribution system. To direct the beam about 1500 magnets (quadrupoles and dipoles) are installed on the machine. Other kind of magnets have the specific purpose to defocus and then focus the beam before the collisions points to fulfil the
1.2 The Large Hadron Collider parameters required for the collisions. The collision between the proton beams generate many secondary particles that can just exist at so high energies. The main purposes of the studied physics in the LHC is recreate the conditions just after the big bang to understand how the universe developed. A lot of other physics investigations are carried out in the four experiments. A brief description of the four experiments installed in the LHC and their purposes is given below:

**ATLAS:** A Toroidal LHC ApparatuS is a particle physics experiment that searches for new particles and processes using head-on collisions of protons of extraordinarily high energy and luminosity. It was designed to investigate a wide range of physics, from the search for the Higgs boson to extra dimensions and particles that could make up dark matter. With its 46 metres length a diameter of 25 metres ATLAS is the larger experiment installed in the LHC. [1]

**CMS:** The Compact Muon Solenoid has the same scientific goals as the ATLAS experiment, but it uses different technical solutions and a different magnet-system design. [1]

**ALICE:** A Large Ion Collider Experiment is a heavy ion detector built to study nucleus-nucleus collisions at high energy. The aim of the experiment is to study the physics of strongly interacting matter at extreme energy densities, where the formation of a new phase of matter, the quark-gluon plasma, is expected. [1]

**LHCb:** The Large Hadron Collider beauty is an experiment set up to study b-physics and it is measuring the parameters of CP violation in the interactions of b-hadrons (heavy particles containing a bottom quark). Such studies can help to explain the Matter-Antimatter asymmetry of the Universe and thus the evolution of matter that constituted the universe in the big bang. [1]
1.3 Vacuum in the LHC

The vacuum system of LHC consists of two main parts which are kept entirely separated in terms of vacuum since they must meet rather different requirements: the cryogenic insulation vacuum necessary to avoid heat load by gas conduction requires a pressure of only about $10^{-6}$ mbar, while the beam vacuum, which must provide a good beam lifetime and low background for the experiments, requires several orders of magnitude of better vacuum for the operation with beam. In the arcs, the ultra-high vacuum is maintained by cryogenic pumping of 9000 cubic metres of gas. As the beam pipes are cooled to extremely low temperatures, the gases condense and adhere to the walls of the beam pipe by adsorption. Just under two weeks of pumping are required to bring the pressures down below $10^{-13}$. Two important design features maintain the ultra-high vacuum in the room-temperature sections. Firstly, these sections make widespread use of a non-evaporable "getter coating", developed and industrialized at CERN, that absorbs residual molecules when vacuum activated. The coating consists of a thin liner of titanium-zirconium-vanadium alloy deposited inside the beam pipes. It acts as a distributed pumping system, effective for removing all gases except methane and the noble gases. These residual gases are removed by 780 ion pumps uniformly distributed along the ring. Secondly, the room-temperature sections allow "bake-out" of all components at 300°C. Bake-out is a procedure in which the vacuum chambers are heated from the outside in order to improve quickly the quality of the vacuum.

1.4 Long Straight Sections

The LHC Long Straight Sections (LSS) are linear sections serving as experimental or utilities insertions. There is a total of 8 LSS covering 5.8 km of the 27 km constituting the LHC ring total length. Here follows a brief description of the LSS and of the components that they host. Figure 1.2 shows a schematic of the LSS.
1.4 Long Straight Sections

- **LSS 1, LSS 2, LSS 5, LSS 8: the experiments** [2]

  In LSS 1, LSS 2, LSS 5, LSS 8 are located ATLAS, ALICE, CMS and LHCb, respectively the four experiments (previously described) and thus the four collision points present in the LHC. LSS 2 and LSS 8 also house the beam injection system from the SPS (TI2 and TI8).

- **LSS 4: Radio Frequency accelerating cavities** [2]

  The RF cavities are used to accelerate the protons. They are molded to a specific size and shape so that electromagnetic waves become resonant and build up inside the cavity. Charged particles passing through the cavity feel the overall force and direction of the resulting electromagnetic field, which transfers energy to push them forwards along the accelerator.
- **LSS 3, LSS 7: Momentum and betatron beam cleaning** [2]

The tight control of beam losses is the main purpose of the collimation system. Movable collimators define aperture restrictions for the circulating beam and should intercept particles on large-amplitude trajectories that could otherwise be lost in the superconducting magnets.

- **LSS 6: Beam dump** [2]

The function of the beam dumping system is to fast-extract the beam in a loss-free way from each ring of the collider and to transport it to an external absorber, positioned sufficiently far away to allow for appropriate beam dilution in order not to overheat the absorber material.

The LSS are mainly constituted by vacuum beam pipes at room temperature, alternated with stand-alone cryostats. The LSS vacuum chambers are made of several materials: bare or copper plated stainless steel, oxygen-free (OFC) and oxygen-free electronic grade (OFE) copper, aluminium, beryllium, copper plated mu-metal (a mainly nickel-iron alloy with high magnetic permeability). OFC refers to a group of special copper alloys ensuring a high electrical conductivity and a small release of oxygen inside the vacuum chambers. OFE copper, in particular, is characterised by only 0.0005% oxygen content.

In addition, these vacuum chambers have disparate lengths (ranging from 20 cm to 7 m), diameters (between 30 mm and 450 mm) and geometries (cylindrical and conical symmetry, circular or elliptical cross-section). However, the baseline for the room temperature beam vacuum system is to use 7 m long OFC copper chambers, with an inner diameter of 80 mm, a wall thickness of 2 mm and fitted with standard DN100 Conflat™ flanges. All these chambers are connected by means of stainless steel bellows equipped with RF copper screens in order to reduce the longitudinal impedance seen by the beam. The chambers are internally coated with a TiZrV non-evaporable getter (NEG) coating, which after having been vacuum activated provides distributed pumping and low outgassing to maintain a low residual gas pressure. Bakeout and NEG vacuum activation must be performed in order to
1.4 Long Straight Sections

Figure 1.3: A room temperature sector (a) and a warm-cold transition(b). In figure (b) is possible to see the end of the room temperature chamber and the beginning of the cryostat.

ensure the required pressure conditions [5]. Reliable residual gas composition and pressure measurements in the $10^{-11}$ mbar range are required in the room temperature part of the beam vacuum system, in order to efficiently check the background conditions for the adjacent experiments and to have early detection of leaks or saturation of the NEG coating. Sector valves are employed to separate the cryogenic and the room temperature sections. The modules housing the sector valves are equipped with bellows, to allow the thermal expansion, and sputter-ion pumps. The maximum distance between two sputter-ion pumps is fixed at about 28 m, to avoid ion-induced pressure instabilities [7]. One Pirani gauge per sector monitors the pressure evolution during the initial pump down from atmospheric pressure. Moreover, every sector is equipped with two cold-cathode ionisation gauges, installed next to the sector valves. Hot cathode ionisation gauges are permanently installed on the central bellow of the sector or available on mobile diagnostic stations. In the centre of each vacuum sector are installed the pumping ports housing the all-metal roughing valves, necessary for the initial pump-down and for the pumping during the bake-out of each sector. Finally, residual gas analysers mounted on mobile stations allow to characterise the residual gas composition after bake-out and NEG vacuum activation.
Chapter 2

Vacuum technology

2.1 Basic notions

If a gas behaves obeying to the *ideal gas equation of state* it can be defined as *ideal*. The *ideal gas equation of state* is

\[ PV = N_{\text{moles}}RT \]  \hspace{1cm} (2.1)

where \( P \) is the pressure, \( N_{\text{moles}} \) the number of moles present in the volume \( V \), \( T \) is the temperature and \( R \) the ideal gas constant (8.314 \( K^{-1}\) \( mol^{-1} \) in SI units). In a first approximation the *ideal gas equation of state* can be considered valid for gas being at atmospheric pressure or below, thus it can be always applied in the framework of vacuum systems in particle accelerators, being the needed pressure some order of magnitude lower than the atmospheric one. Equation 2.1 can be rewritten in terms of the total number on molecules \( N \) in the system:

\[ PV = Nk_bT \]  \hspace{1cm} (2.2)

being \( k_b \) the Boltzmann constant (1.38 \( \cdot \) \( 10^{-23} JK^{-1} \) in SI units).
2.1.1 Gas kinetics

Consider \( N \) molecules of mass \( m \) in a volume \( V \) each of them having a different velocity \( \vec{v} \), with three components \( c_x, c_y \) and \( c_z \) on the three space axis \( x, y, z \). Assuming that:

- \( \vec{v} \) ranges from 0 to \( \infty \).
- particles are seen as point masses.
- if two particles are separated by a distance \( r < R \) a repulsion is exerted between them and they behave like perfectly elastic spheres of radius \( R/2 \).
- collision between particles produces a change both in velocity and direction of the particles themselves.

and considering that particles undergo frequent collisions, thus not having a constant velocity and specific directions, it is possible to demonstrate that particle velocity distribution can be described by Maxwell-Boltzmann distribution. The average particle speed can thus be written as follows:

\[
\langle v \rangle = \sqrt{\frac{8k_B T}{\pi m}} = \sqrt{\frac{8RT}{\pi M}}
\]  

(2.3)

where \( M \) is the molar mass. Some typical values of \( \langle v \rangle \) at room and cryogenic temperature are shown in Table 2.1.

<table>
<thead>
<tr>
<th>( \langle v \rangle ) at 293 K ( [\frac{m}{s}] )</th>
<th>( H_2 )</th>
<th>( H_2 )</th>
<th>( CH_4 )</th>
<th>( N_2 )</th>
<th>( Ar )</th>
</tr>
</thead>
<tbody>
<tr>
<td>1761</td>
<td>1244</td>
<td>622</td>
<td>470</td>
<td>394</td>
<td></td>
</tr>
</tbody>
</table>

| \( \langle v \rangle \) at 4.3 K \( [\frac{m}{s}] \) | 213 | 151 | 75 | 57 | 48 |

Table 2.1: Average molecular speed for different gases and temperature.

The Maxwell-Boltzmann theory allows to define the impingement rate, namely the rate at which gas molecules collide with a unit surface area. Assuming the molecule density \( n \) uniform in the considered volume and \( \langle v \rangle \) the average molecular speed defined above, it is possible to write
2.1 Basic notions

\[ \varphi = \frac{1}{4} n \langle v \rangle = \frac{1}{4} n \sqrt{\frac{8RT}{\pi M}} \]  

(2.4)

2.1.2 Flow regimes

Mean free path

The mean free path is defined as the average distance covered by a molecule between two collisions. In a defined volume these collisions can occur with another molecule or with the wall of the system. The mean free path can be written as

\[ \lambda = \frac{1}{\sqrt{2n\sigma_c}} \]  

(2.5)

where \( n \) is the molecule density and \( \sigma \) is the collision cross section. Being \( n = \frac{p}{k_B T} \) and \( \delta \) the molecular diameter, the definition of mean free path becomes

\[ \lambda = \frac{k_B T}{\sqrt{2\pi\delta^2 P}} \]  

(2.6)

Knudsen number

When the typical dimension of the system is of the same order of the mean free path the molecule-wall collisions becomes dominant. For even longer \( \lambda \) the molecule-molecule collisions can be neglected and only the molecule-wall ones are considered. In order to describe the different cases above, the Knudsen number is introduced. This adimensional quantity is defined as:

\[ K_n = \frac{\lambda}{D} \]  

(2.7)

where \( D \) is the characteristic dimension of the system (the pipe diameter for accelerators). The Knudsen number defines three different flow regimes with the properties listed in Table 2.2

In UHV systems the assumption of free molecular flow can always be considered true.
Table 2.2: Gas dynamics regime described by Knudsen number.

<table>
<thead>
<tr>
<th>$K_n$ range</th>
<th>Regime</th>
<th>Description</th>
</tr>
</thead>
<tbody>
<tr>
<td>$K_n &lt; 0.01$</td>
<td>Continuous Flow</td>
<td>Gas dynamic dominated by intermolecular collisions</td>
</tr>
<tr>
<td>$0.01 &lt; K_n &lt; 0.5$</td>
<td>Transitional Flow</td>
<td>Transition between molecular and viscous flow</td>
</tr>
<tr>
<td>$K_n &gt; 0.5$</td>
<td>Free Molecular Flow</td>
<td>Molecule-wall collisions dominate</td>
</tr>
</tbody>
</table>

2.1.3 Conductance and gas flow

In molecular flow it is possible to define the gas flow rate. In vacuum technology this quantity is usually expressed in terms of pressure-volume (or $PV$-throughput) and expresses the number of molecules flowing into a fixed volume $V$ at pressure $P$ at a temperature $T$.

$$ Q = PV = P \frac{dV}{dt} \quad (2.8) $$

This quantity is proportional to the pressure difference between two points of the considered system.

Figure 2.1: Schematic drawing of two volumes communicating through a thin and small wall slot

If we consider, for instance, the system in Figure 2.1, the gas flow rate between the two communicating volumes can be written as follow:

$$ Q = C(P_1 - P_2) \quad (2.9) $$
2.1 Basic notions

$C$ is called conductance and it depends only on the geometry of the system and on the molecular speed inside it. Since $Q$ is expressed in $[\text{mbar} \cdot \ell \cdot s^{-1}]$ the conductance take the form of a volumetric flow rate, thus $[\ell \cdot s^{-1}]$.

The net flow rate between the two volumes can be calculated using the impingement rate described in section 2.1.1. It is given by the difference between the number of molecules passing through the orifice of surface $A$ from left to right and from right to left. Considering thus

$$\varphi_{1 \rightarrow 2} = \frac{1}{4} A n_1 \langle v \rangle$$

(2.10)

and

$$\varphi_{2 \rightarrow 1} = \frac{1}{4} A n_2 \langle v \rangle$$

(2.11)

the net flow will result as

$$\varphi = \varphi_{1 \rightarrow 2} - \varphi_{2 \rightarrow 1} = \frac{1}{4} A (n_1 - n_2) \langle v \rangle = \frac{1}{4} A \langle v \rangle \frac{(P_1 - P_2)}{k_b T}$$

(2.12)

Multiplying then the first and the last term of Equation 2.12 for $k_b T$ and expressing $\varphi$ in terms of $PV$:

$$Q = \frac{1}{4} A \langle v \rangle (P_1 - P_2)$$

(2.13)

and thus

$$C = \frac{1}{4} A \langle v \rangle \propto \sqrt{\frac{T}{m}}$$

(2.14)

As shown in Equation 2.14 the conductance is inversely proportional to the square root of the molecular mass of the gas, so the smaller is the mass of the gas the higher is the conductance. The ratio between the conductances for two different gas is

$$\frac{C_1}{C_2} = \sqrt{\frac{m_2}{m_1}}$$

(2.15)

Considering for instance $N_2$ and $H_2$ it is possible to see that the conductance of nitrogen $C_{N_2} = C_{H_2} \times \sqrt{\frac{28}{2}} = 3.74 \times C_{H_2}$. In Table 2.3 are reported
the conductances per unit area (expressed in \( cm^2 \)) for the main gases present in typical accelerators vacuum systems.

Table 2.3: Unit surface area conductances for common gas species in two different units.

<table>
<thead>
<tr>
<th></th>
<th>( H_2 )</th>
<th>( He )</th>
<th>( CH_4 )</th>
<th>( H_2O )</th>
<th>( N_2 )</th>
<th>( Ar )</th>
</tr>
</thead>
<tbody>
<tr>
<td>C at 293 K ( \left[ \frac{f}{cm^2 s} \right] )</td>
<td>44</td>
<td>31.1</td>
<td>15.5</td>
<td>14.7</td>
<td>11.7</td>
<td>9.15</td>
</tr>
</tbody>
</table>

**Series and parallel conductances**

In analogy with electric circuits, it is possible to calculate the conductance resulting by the connection of more conductances. In the electrical analogy we can consider the flow rate as a current and the pressure difference as the potential difference. Thus the conductance can be considered as the inverse of the resistance in an electric circuit (following the relations \( Q = C \Delta P \) and \( \Delta V = RI \)).

Figure 2.2 shows an example of series and parallel conductances.

If two pipes are connected in parallel the resulting conductance is:

\[
C_{tot} = \sum_i C_i \tag{2.16}
\]
For a series connection of $i$ conductance is valid the relationship:

$$\frac{1}{C_{tot}} = \sum_i \frac{1}{C_i} \quad (2.17)$$

**Conductance of an aperture**

In free molecular flow regime intermolecular collisions can be neglected. If we consider a thin-wall orifice, no collisions between the molecules and the radial wall of the aperture will take place. It implies that all the particles passing through the aperture cannot be backscattered, leading to a transmission equal to one.

Therefore the conductance of an aperture can be written as:

$$C_{Ap} = \frac{\langle v_x \rangle}{4} A \quad (2.18)$$

where $\langle v_x \rangle$ is the average x-component of velocity for a Maxwell-Boltzmann distribution and $A$ is the cross-section of the aperture expressed in $cm^2$. Remembering then that

$$\frac{\langle v_x \rangle}{4} = \sqrt{\frac{RT}{2\pi M}} \quad (2.19)$$

the conductance can be easily calculated knowing the thermodynamic parameters of a system.

**Conductance of a pipe with constant cross section**

In the case of a pipe the thin-wall assumption is not valid anymore. Thus backscattering occurs and not all the particles entering the system are transmitted through it. The conductance of a tube can be calculated multiplying the conductance of an aperture $C_{Ap}$ by a proper factor, $Pr$, representing the proportion of particles leaving the exit of the conductance:

$$C_{Pipe} = C_{Ap} Pr \quad (2.20)$$

$Pr$ can be interpreted as the ratio between a “transmitting” area and an “obstructing”. The latter is proportional to the total surface of the pipe.
Being \( h \) the perimeter of the pipe, \( l \) its length and \( A_{tr} \) the transmitting area, \( Pr \) can be expressed as:

\[
Pr = \frac{A_{tr}}{A_{tr} + lh} \tag{2.21}
\]

Introducing then some correction factors taking into account that \( A_{tr} \) is usually larger than the actual cross-section \( A \) and that the obstructing area is smaller than \( lh \) we obtain the final formula for the conductance of a pipe

\[
C_{pipe} = C_{Ap}(1 + \frac{3}{16} \frac{lh}{A}) \tag{2.22}
\]

### 2.1.4 Pumping speed

Pumping speed \( S \) is namely defined as the ratio between the gas flow entering the pump \( Q_p \) and the pump-inlet pressure \( P \) and is usually expressed in \( ℓs^{-1} \).

\[
S = \frac{Q_p}{P} \tag{2.23}
\]

The pump throughput can be written as the gas flow \( \varphi \) through the cross section of the pump inlet (surface area \( A_p \)) multiplied by the sticking probability \( s \), i.e. the probability for a molecule that enters the pump to be definitely removed and never more reappear in the gas phase of the vacuum system.

\[
Q_p = \varphi A_p \sigma = \frac{1}{4} A_p n \langle v \rangle s \tag{2.24}
\]

Remembering the definition of the conductance \( C \) and the molecule density \( n \) we can write

\[
Q_p = s A_p C \frac{p}{k_b T} \tag{2.25}
\]

Converting now the throughput in PV-units and applying the definition of pumping speed we obtain

\[
S = s A_p C \tag{2.26}
\]
Therefore, the pumping speed is equal to the conductance of the pump inlet cross section multiplied by the capture probability. The maximum theoretical pumping speed of any pump is obtained for $s = 1$ and it is equal to the conductance of the pump-inlet cross section.

Figure 2.3: Schematic of a vacuum system connected to a pump.

Figure 2.3 shows a schematic of a vacuum system. $S_0$ is the pumping speed at the inlet of the pump. To take into account the resistance to the gas flow of pipes and valves the effective pumping speed $S_{Eff}$ is introduced. This quantity represents the pumping speed as seen at the entrance of the vacuum system and is given by:

$$\frac{1}{S_{Eff}} = \frac{1}{S_0} + \frac{1}{C_{tot}}$$

(2.27)

For very low conductance values ($C << S_0$) $S_{Eff} = C_{tot}$.

2.1.5 Gas loads in UHV systems

The lower limit to the pressure that can be reached in a vacuum system is imposed by the gas load coming out from different sources. Three main sources of gas load can be identified: outgassing, leaks, permeation.
Leaks  Vacuum systems are made of many components connected by means of flanges of different typology. Leaks can be defined as a flow of gas passing through the connections between two flanges [11]. They are due to the pressure difference between the atmosphere and the insight of the vacuum system. Even if it is impossible to totally eliminate leaks, they can be limited enough to allow the achievement and maintenance of the required vacuum performances. In the LSS of LHC the leak tightness of the system is provided using CF (ConFlat) flanges. CF (ConFlat) flanges use a copper gasket and knife-edge flange to achieve an ultrahigh vacuum seal. A schematic of a CF flange is shown in Figure 2.4.

![Figure 2.4: ConFlat flange schematic.](image)

Outgassing  During the manufacturing of a material or its exposure to air, gas is absorbed in the bulk or on the surface of the material itself. The re-emission of this gas in a vacuum system is called outgassing. The outgassing rate of a material strongly depends on the microscopic structure of the surface, thus a good modelling of this phenomenon results difficult. To face up this problem, measurement of the outgassing rate has been performed.
on many materials [9]. By the measured data it was developed a model to describe the outgassing for different materials.

\[
\dot{q}_{\text{outgassing}} = \frac{a_{1h}A}{(t/1h)^\alpha}
\]  

(2.28)

where \(A\) is the geometrical surface area, \(a_{1h}\) is a fit parameter identified as the specific outgassing after 1 h and \(\alpha\) is the negative slope of the outgassing curve presented in Figure 2.5 [11].

Figure 2.5: Time-dependence of the outgassing flow rate for different materials [11].

**Permeation** Permeation occurs when a gas is adsorbed on high-pressure side of a material, diffused through it and eventually desorbed on the low pressure side. Materials used in the construction of UHV systems can be considered impermeable to air even at high temperature. Permeability is usually observed for \(H_2\), considering the high diffusivity in metals even at room temperature.
Bake-out effects on outgassing

When a metal is exposed to air its surface is covered by a homogeneous oxide layer, by a mix of hydroxide and hydrocarbons and, above all, by water molecules. While at atmospheric pressure, due to its polar nature, water is strongly bonded to the metallic surface, in vacuum conditions water desorption dominates the degassing of metals, according to Equation 2.29.

The frequency $\nu$ of molecules desorption from a surface corresponds to the probability of desorption per adsorbed species per unit time and it is given by:

$$\nu = \nu_0 e^{-\frac{E}{k_B T}}$$

(2.29)

The desorption frequency depends on the binding energy $E$ between a molecule and the surface, thus on the type of gas and surface material, and on the temperature $T$. In order to reduce the outgassing of a surface during operations vacuum systems undergo a procedure called bake-out [9]. After the mechanical pumpdown of the vacuum system, the metal components are heated up in order to accelerate the desorption of water molecules from the surface. During bake-out the system is connected to the pumping group, which remove the desorbed water molecules. Figure 2.6 shows the pressure evolution during bake-out.

During the bake-out of a vacuum system, pressure drastically increases of several orders of magnitude, due to the enhanced desorption from the inner metallic surfaces. Once the bake-out is over and all the water has been desorbed and pumped, the degassing of a vacuum system becomes dominated by hydrogen, which does not come from the surface but rather from the bulk of the metallic components, where this gas is usually included during metal-lurgic processes. In addition to $H_2$, the other main residual gases generally present in a vacuum system after a bake-out are $CO$, $CO_2$ and hydrocarbons (in particular $CH_4$).
2.2 Vacuum instrumentation

2.2.1 Vacuum pumps

Mechanical pumps

Primary pump These are volumetric pumps used to provide the first pumping stage, reaching a minimum ultimate pressure in the order of $10^{-3}$. The most used are oil sealed rotary pumps, dry pumps and piston pumps.

Turbomolecular pump A turbomolecular pump is a multi-stage, bladed turbine in which the rotor is driven at high rotational speeds, so that the peripheral speed of the blades is of the same order of magnitude of the thermal velocity $\langle v \rangle$ of the gas molecules to be pumped. A pumping stage is composed of a rotor, which transfers the momentum to the particles, and a stator, whose function is to randomize the angular distribution of the velocities between a stage and the next one. In Figure 2.7 it is possible to see the multiple-stages structure.

The most important parameters of a TMP are the pumping speed and the compression ratio $k_g$ for a particular gas $g$. $k_g$ is defined as:
where $p_{g,\text{forevac}}$ and $p_{g,\text{inlet}}$ are the pressure at the first and the last pumping stage respectively. TMP pumps can reach pressures in the order of $10^{-9}$.

**Capture pumps**

Gas binding pumps are vacuum pumps that removes gas particles from the system by sorption effects such as chemisorption or implantation. These kind of pumps are used in UHV systems, where the contamination by lubricants and pump fluids, for instance, must be avoided.

**Sputter-ion pumps** The pumping effect of sputter-ion pumps is produced by sorption processes, which are released by ionised gas particles. The pumping speed is achieved by parallel connection of many individual Penning cells. A sputter-ion pump consists basically of two electrodes, anode and cathode, and a magnet. The anode is usually cylindrical and made of stainless steel. The cathode plates positioned on both sides of the anode tube are made of titanium, which serves as gettering material (Figure 2.8). The magnetic field is oriented along the axis of the anode. Electrons are emitted from the
2.2 Vacuum instrumentation

cathode due to the action of an electric field and, due to the presence of the magnetic field, they move in long helical trajectories which improve the chances of collision with the gas molecules inside the Penning cell. The usual result of a collision with the electron is the creation of a positive ion that is accelerated to some kV by the anode voltage and moves almost directly to the cathode. The influence of the magnetic field is small because of the ion’s relatively large atomic mass compared to the electron mass.

Figure 2.8: Schematic drawing depicting the pumping mechanism of sputter ion pumps in the diode configuration.

Ions impacting on the titanium cathode surface sputter titanium away from the cathode, forming a getter film on the neighbouring surfaces and stable chemical compounds with the reactive or "getterable" gas particles (e.g. CO, CO₂, H₂, N₂, O₂). This pumping effect is very selective for the different types of gas and is the dominating effect with sputter ion pumps. The number of sputtered titanium molecules is proportional to the pressure inside the pump. The sputtering rate depends on the ratio of the mass of the bombarding molecules and the mass of the cathode material. The higher this ratio, the higher is the sputtering rate. For hydrogen, the lightest gas molecule, the sputtering rate of titanium is negligible. In addition to the sputtering process a second important effect can be observed. The energy of the ionised gas particles allows some of the impacting ions to penetrate deeply (order of magnitude 10 atomic layers) into the cathode material. This sorption process pumps all kinds of ions, in particular ions of noble gases which do not react chemically with the titanium layer formed by sputtering. However, this pumping effect is not permanent since, due to the erosion of the
cathode material, previously implanted molecules are released. The cathode sorption process also works for hydrogen. Large amounts of hydrogen ions can diffuse deep into the bulk material beyond the range of the implanting ions and are permanently buried [28].

2.2.2 Vacuum gauges

In the framework of all the measurement instrumentation employed in vacuum technology we are going to describe, in this chapter, the two pressure gauges used in this work: the Bayard-Alpert gauge, used for total pressure measurement, and the Residual Gas Analyser (RGA) used for partial pressure measurement.

Bayard-Alpert gauge

Bayard-Alpert (BA) gauge is a hot cathode ionization gauge. A schematic and a picture of a BA gauge are shown in Figure 2.9.

![Figure 2.9: A schematic of a Bayrad-Alpert gauge (a). In (b) is shown an example of BA gauges employed in the LHC.](image)

A current of electrons $I^-$ is emitted by a heated filament and accelerated through a voltage between the cathode (filament) and the anode (grid). Gas particle are thus ionized by the electrons and travelled to the ion collector,
negatively biased, and the ion current $I^+$ is measured. Consider now $N^-$ electrons passing from cathode to anode, travelling a length $l$, through a gas of particle number density $n$ and collision cross-section $\sigma$ (dependent on the type of gas and the electron energy). If $\Delta N^-$ ionizing collisions take place then:

$$\Delta N^- = N^- n \sigma l$$  \hspace{1cm} (2.31)

Any successful electron collision will form a positive ion, so it results that $\Delta N^- = \Delta N^+$. The number of ion pairs formed per electron per unit of path length through the gas of particle density $n$ is given by:

$$\Delta N^- \over N^- l = n \sigma$$  \hspace{1cm} (2.32)

Dividing by time Equation (2.31) the ion current $I^+$ is obtained as a function of the electronic current ($I^-$) between the cathode and the anode.

$$I^+ = \frac{\Delta N^+}{t} = \frac{\Delta N^-}{t} = \frac{N^-}{l} n \sigma l = I^- n \sigma l$$  \hspace{1cm} (2.33)

Since $n = P/k_b T$ we can finally write:

$$I^+ = I^- \frac{\sigma l P}{k_b T} = I^- K P$$  \hspace{1cm} (2.34)

where $K$ is the gauge constant. It depends on the gauge geometry, the type of gas and other several factors.

Different gases have different collision cross section for a certain electron energy (Figure 2.10). The gauges are thus calibrated using $N_2$ as reference gas and a correction factor $\gamma$ has to be applied if the actual pressure for a different gas is needed:

$$P_{actual} = P_{read} \cdot \gamma$$  \hspace{1cm} (2.35)

Table 2.4 reports the values of $\gamma$ for some different gases.

The electron energy is typically of 100 eV. It is possible to see in Figure 2.10 that it corresponds to the maximum collision cross section for $N_2$, but not for the other gases and that some gas have lower cross section and some
Table 2.4: Correction factors $\gamma$ for different gases.

<table>
<thead>
<tr>
<th>Gas</th>
<th>Kr</th>
<th>$CO_2$</th>
<th>$CH_4$</th>
<th>Ar</th>
<th>$CO$</th>
<th>$N_2$</th>
<th>$H_2$</th>
<th>$He$</th>
</tr>
</thead>
<tbody>
<tr>
<td>$\gamma$</td>
<td>0.59</td>
<td>0.69</td>
<td>0.7-0.8</td>
<td>0.83</td>
<td>0.92-0.95</td>
<td>1</td>
<td>2.4</td>
<td>6.9-7.1</td>
</tr>
</tbody>
</table>

other have higher.

Figure 2.10: Ionization cross section as a function of electron energy.

There are two effects affecting BA gauge measurement, namely the X-ray effect and the gas-ion desorption that are described below:

**X-ray effect**  When the electrons collide with the anode, x-rays are emitted. The so created photons impinge on the cathode generating new electrons from photoelectric effect and increasing the measured current. It implies that the pressure read by the gauge will be higher than the real one. The X-ray effect limits the lower measurable pressure value to $10^{-12} \text{mbar}$.

**Gas-ion desorption**  When the BA gauge is switched on the current starts to flow in the filament. The joule effect induces the heating up of the filament,
and thus an initial gas desorption from its surface. The ionization of this gas gives a read pressure higher than the real one.

**Residual Gas Analyser**

Residual Gas Analyser (RGA) is used to identify the components present in a gas phase in a vacuum system. It is really useful to know the gas phase composition to have information about the eventual presence of leaks or about the system cleanliness. Furthermore, knowing the precise composition makes possible the easy calculation of the partial pressures of the different gases. Figure 2.11 shows a schematic of an RGA.

![Schematic of a Residual Gas Analyser](image)

*Figure 2.11: Schematic of a Residual Gas Analyser.*

An ion beam generated in the ionizer passes to the mass separation system, where a continuous change in the voltage applied to the electrodes allows ions of the appropriate mass/charge \((m/z)\) ratio to pass to the detector. The current related to each \(m/z\) indicates the amount of each species present in the system.

The sensitivity \(S\) for every \(m/z\) can be expressed as the ratio between the ion current \(I^+_{M/Z}\) and the measured pressure \(P_{M/Z}\):

\[
S_{RGA} = \frac{I^+_{M/Z}}{P_{M/Z}}
\]  
(2.36)
RGA has different sensitivities for different gases, considering, as in the case of hot ionization gauge, that every gas has different ionization cross-section. To face up with this problem the RGA sensitivity is established for one reference gas (N₂ for instance). The sensitivities for other gases can be found multiplying the reference sensitivity by appropriate correction factors. During ionization gas molecules can fragment, so it is possible to have different m/z associated with the same species. To take it into account, the cracking (or fragmentation) pattern is introduced. As an example Table 2.5 show cracking pattern values for H₂O.

Table 2.5: Cracking pattern f measured for H₂O for ionizing electron energy of 102 eV.

<table>
<thead>
<tr>
<th>Ion</th>
<th>M/Z</th>
<th>% of major peak</th>
<th>f</th>
</tr>
</thead>
<tbody>
<tr>
<td>H₂O</td>
<td>18</td>
<td>100</td>
<td>0.74</td>
</tr>
<tr>
<td>OH⁺</td>
<td>17</td>
<td>25</td>
<td>0.185</td>
</tr>
<tr>
<td>O⁺</td>
<td>16</td>
<td>2</td>
<td>0.015</td>
</tr>
<tr>
<td>H₂⁺</td>
<td>2</td>
<td>2</td>
<td>0.015</td>
</tr>
<tr>
<td>H⁺</td>
<td>1</td>
<td>6</td>
<td>0.044</td>
</tr>
<tr>
<td>TOT</td>
<td></td>
<td>135</td>
<td>0.99</td>
</tr>
</tbody>
</table>

Almost all gases fragment during ionization. Two different methods can be used for the determination of partial pressure values:

- To sum all the ion currents associated with the fragments belonging to a species. To use this method all the mass fragments (M₁, M₂, etc.) related to a species have to be identified. The partial pressure for the gas G, p₉, is than given by:

\[
p_G = \frac{\sum_{i=1} I_{M_i}^+}{S_{RGA_G}} = \frac{I_{TotG}^+}{S_{RGA_G}}
\]  \hspace{1cm} (2.37)

- To select one unambiguous mass fragment (M₉) with its related ion current I₉⁺ and dividing it for the appropriate fragmentation factor f₉ in order to obtain the total ion current related to the selected species. In this case the partial pressure is given by:
2.2 Vacuum instrumentation

\[ P_G = \frac{I_{M_g}}{M_g S_G} \] (2.38)

RGA allows to know the gas composition into a system. All the \( m/z \) values are progressively selected by the mass separator. The current collected for each \( m/z \) values is proportional to the amount of species in the system. The result of measurement is a spectrum of all the currents related to each \( m/z \) (Figure 2.12).

Figure 2.12: Example of spectrum taken by RGA on an unbaked stainless steel system.

It is possible to observe in Figure 2.12 the peaks on 16, 17 and 18 related to the different ionized fragments of \( H_2O \). The cracking pattern is calculated considering the maximum intensity of the peak related to each species.
2.3 Characterization methods

To quantify the pumping performance of a NEG coated chamber we use the sticking factor $s$, defined as the probability for a molecule to be permanently adsorbed on a surface. The main problem to face up is to experimentally evaluate $s$. For this purpose in the following sections we will describe in detail how the sticking factor can be obtained combining an experimental and a computational approach. In this section the transmission method will be introduced and discussed, while in the next one we will see how the obtained results can be used for the calculation of $s$.

2.3.1 Transmission method

Total pressure

The configuration for the characterization of a NEG coated chamber is schematically shown in Figure 2.13.

Figure 2.13: Example of configuration for the transmission method.

The transmission is defined as the ratio between the variation of pressure on BA gauge 1 and the variation on BA gauge 2 while injecting gas in the system. The injected gas are $H_2$, $N_2$ and $CO$, which are those pumped by NEG. The transmission for a certain gas $G$ is thus given by:

$$Tr_{P,tot,G} = \frac{\Delta P_{BA1,G}}{\Delta P_{BA2,G}}$$  \hspace{1cm} (2.39)
2.3 Characterization methods

Figure 2.14: Pressure evolution during $H_2$ injection.

Figure 2.14 shows the pressure trend on BA gauge 1 and 2 during an $H_2$ injection. The injection is performed in many steps. The gas flow regulation is provided by a variable leak valve. Transmission changes during the injection until it reaches a steady value, which is considered as the reliable one. Figure 2.15 shows the evolution of the transmission values during the injection considered in Figure 2.15.

Figure 2.15: Transmission evolution during $H_2$ injection.
Partial pressure

More accurate transmission values can be obtained using the ratio between the partial pressures instead of the ratio between total pressures. To evaluate the partial pressure two RGAs are installed in front of the BA gauges. A schematic of the modified system is shown in Figure 2.16. As explained in 2.2.2 knowing the current related to a species and the sensitivity of the RGA for that species it is possible to calculate the partial pressure of the considered gas.

![Schematic of partial pressure transmission measurement configuration.](image)

The partial pressure transmission for a certain gas G will be then:

\[
Tr_{P,par_G} = \frac{\Delta P_{par,1G}}{\Delta P_{par,2G}}
\]  

(2.40)

Figure 2.17 and Figure 2.18 show the evolution of the currents related to different m/z values during an H₂ injection. It is possible to notice that not only the current related to the injected gas increases. It means that other species (usually He and CH₄, m/z = 4 and m/z = 16 respectively) are injected or produced during the injections.
2.3 Characterization methods

Figure 2.17: Evolution of ion currents during an $H_2$ injection on the RGA 1.

Figure 2.18: Evolution of ion currents during an $H_2$ injection on the RGA 2.
2.3.2 Numerical simulations for pressure distribution analysis

In a particle accelerator the estimation of residual gas density profiles is indispensable to properly design the components and guarantee vacuum stability. Moreover, in the experimental insertion regions, density profiles are extremely important to estimate machine background effects in the detectors generated by proton or ion-gas scattering. In a hadron collider, beam induced dynamic effects such as ion, electron and photon-stimulated gas desorption are the main source of residual gas. In order to estimate the pressure profiles two different numerical simulation software were developed at CERN, namely Molow+ and VASCO.

Molow+

Molow+ is a C++ code which implements test-particle Monte Carlo (TPMC) method to describe the residual gas flow into an arbitrary three-dimensional geometry [16]. CAD drawings can be imported in Molow+, that re-elaborate the geometry dividing it in planar facets. For each facet it is possible to set the parameters typically characterizing a vacuum system, such as surface outgassing, sticking probability and pumping speed.

Pressure profiles on every facet composing the system can be plotted, allowing the evaluation, for instance, the transmission between two gauge for a given sticking factor value or the effective pumping speed. In this study Molflow+ was used to create $Tr-s$ curves, which allow to calculate, given the transmission experimentally measure on a test bench, the sticking factor of the NEG thin film.

Figure 2.19 shows the typical Molflow+ interface. The coloured part is a texture in which every colour corresponds to a specific pressure values, while the box on the right of the screen is the pressure profile along the considered system. For a detailed description the theoretical basics of (TPMC) see [16]and [18].
2.3 Characterization methods

Figure 2.19: Example of Molflow+ interface with the main functions.

**VASCO code**

The VAcuum Stability COde (VASCO) allows the estimation of residual gas density profiles. The code treats the vacuum system as a sequence of elements linked with boundary conditions. It was used to verify the vacuum stability and beam life time during the LHC design. In the calculation of the rate of change of molecules density per unit volume, four parameters are taken into account:

- Molecular diffusion along the chamber due to pressure gradient.
- Beam induced dynamic effects (ion, electron and photon-stimulated desorption)
- Distributed pumping along the pipe (cryopumping, NEG pumping)
- Gas lumped pumping (sputter-ion pumps)

VASCO is a finite elements code, which divides the vacuum system in several elements, each one characterised by a different set of parameters;
boundary conditions must be properly set in order to ensure the continuity of gas density and flux between each pair of elements. The model uses cylindrical geometries allowing for one-dimensional approximation along the beam axis. Moreover, the parameters are assumed to be time invariant, it means that the gas density is estimated as relevant to a specific moment in time. The set of equations describing the gas density takes into account the influence that one species has on the desorption of the others. Thus the equations for each gas are linked to the ones for the other species. VASCO code is implemented in Matlab, so the input file must be a rectangular matrix without empty spaces. The input file is prepared in Excel, than saved as text file [23]. An example of an input file is given in Figure 2.20.

![Figure 2.20: Example of VASCO input file.](image)

### 2.3.3 Bake-out and NEG activation

As seen in 2.1.5, bake-out allows to remove water molecules from the surface of metal components of a vacuum system. In this section the bake-out and activation procedure will be presented.

- The system is pumped down for at least 12 hours.

- Leak detection is done connecting a leak detector [13], a mass spectrometer which detects helium, downstream the TMP. Then the outer
2.3 Characterization methods

surface of the flange to be tested is sprayed with a localized stream of helium. If a leak is encountered the helium molecules will penetrate in the vacuum system and will be detected by the mass spectrometer.

- If the system is leak tight the bake-out can be started. The components are heated by means of dedicated heating collars, jackets or tapes depending on the geometry of the component. Figure 2.21 shows the bake-out and activation steps.

![Figure 2.21: Bake-out and activation procedure.](image)

As it is possible to notice different components are heated at different temperatures (a detailed description will be given in Chapter 5).

- In the first step of bake-out all the non-NEG coated components are heated up to the maximum temperature for 24 h in order to allow the desorption of all water molecules from the surface, while the NEG coated parts are kept at 120°C in order to avoid water molecules condensation on the surface.

- In step two the baked components are cooled down to 120-180°C (depending on the kind of component) and a spectrum is taken with the RGA to check the composition of residual gas in the system. Then the NEG coated parts are heated up to 230°C in order to al-
low NEG activation. Pressure evolution during activation is shown in Figure 2.22.

![Figure 2.22: Pressure evolution during NEG activation.](image)

The degas of the instrumentation is performed again at the end of the activation cycle.

- In the third step the system is cooled down to room temperature.
- After 12 hours the pressure values in the chamber are checked in order to confirm that the activation took place properly.
Chapter 3

Non-Evaporable Getters

3.1 Getter materials

Getter materials are defined as materials that can chemically pump gas molecules by fixing them on an internal surface. Those materials, which can be considered as chemical pumps, are employed in Ultra High Vacuum applications, providing pressure values in a range between $\sim 10^{-7} \text{mbar}$ and $\sim 10^{-12} \text{mbar}$. Chemical pumps are generally characterized by a quantity called \textit{mean sojourn time}, namely the time spent by a captured molecule on the pumping surface. The mean sojourn time is defined as

$$\tau = \tau_0 e^{\frac{E_b}{RT}}$$ (3.1)

where $\tau_0$ is the vibrational period of the absorbed molecule, $T$ is the temperature, $E$ is the binding energy and $R$ is the universal gas constant. The molecule can be considered permanently adsorbed by the chemical pump if $\tau$ is big enough in comparison with the duration of the experiment. While for physiosorption the bond between gas and surface molecules is due to Vander Waals forces, which provide a binding energy lower than $50 Kj\cdot mol^{-1}$, for chemisorption a chemical reaction is implied. Covalent, ionic or metallic bonds are in this case involved, providing binding energies even much higher than $50 Kj\cdot mol^{-1}$. NEG materials can be used at room temperature, having a sojourn time that could be reached just at cryogenic temperature in case
of physiosorbing materials. In order to allow the reaction between the gas molecules and the surface getter layer, it has to be free of contamination and, more precisely, the native oxide layer has to be removed. The removal of the oxide layer is provided by heating the material; this process is called activation. As a consequence of the fact that in chemisorption mechanism a chemical reaction is implied, inert gases like noble gases cannot be pumped by getter materials. All the other gases, (except $H_2$ which can diffuse in the bulk and $CH_4$ that is not pumped by getters) remain on the getter surface when adsorbed, progressively occupying the surface free sites and reducing the pumping speed of the getter itself.

Depending on the production process adopted for the active surface production, getter materials are divided in two families:

- **Evaporable getters**: the active layer is obtained under vacuum by sublimation of a fresh metallic film.

- **Non-Evaporable Getters (NEG)**: the active surface is produced by thermal diffusion of the contaminants present on the layer into the bulk of the getter itself.

For most of the baked vacuum systems the main residual gas is $H_2$. The mechanism of $H_2$ solution in a getter material takes place in three main steps. The first step consists in the molecule dissociation at the gas surface interface. Afterwards the dissociated particles create chemical bonds with the free sites on the surface. At last the atoms diffuse in the bulk of the getter material. Unlike all other gases, $H_2$ sorption in the getter material is thermally reversible. The dissociation pressure $P_{H_2}$, which describes the equilibrium between the flux of thermal desorption and the flux of pumping of $H_2$, is defined, according to Sievert’s law, as:

$$P_{H_2} = A \cdot c^2 \cdot e^{\frac{\Delta H}{k_b T}}$$  \hspace{1cm} (3.2)

where $\Delta H$ is the reaction enthalpy, $A$ is a constant which includes the entropic contribution towards the dissociation reaction of $H_2$, $c^2$ is the concentration of mono-atomic hydrogen solid solution, $k_b$ is the Boltzmann constant and $T$ the temperature of the getter. In UHV conditions the dissolution
pressure has to be very low, in order to have a solid solution thermodynamically stable. [22].

The thermodynamic description of the activation mechanism of a getter material can be obtained considering the Gibbs free energy variation of the oxide $\Delta G_{\text{ox}}$ and of the solid solution $\Delta G_{\text{ss}}$ per oxygen atom.

\[
\Delta G_{\text{ox}} = \Delta H_{\text{ox}} - T \cdot \Delta S_{\text{ox}} \tag{3.3}
\]

\[
\Delta G_{\text{ss}} = \Delta H_{\text{ss}} - T \cdot \Delta S_{\text{ss}} \tag{3.4}
\]

where $\Delta H$ and $\Delta S$ are the variation of enthalpy and of entropy of the two states respectively. The Gibbs free energy has to be negative to allow the dissolution of the oxide in the solid solution:

\[
\Delta G_{\text{tot}} = \Delta G_{\text{ss}} - \Delta G_{\text{ox}} < 0 \tag{3.5}
\]

and thus,

\[
\Delta H_{\text{ss}} - \Delta H_{\text{ox}} < T(\Delta S_{\text{ss}} - \Delta S_{\text{ox}}) \tag{3.6}
\]

The entropic term is always negative. Thus there are two ways in which the dissolution can occur.

- $\Delta H_{\text{ss}} > \Delta H_{\text{ox}} \tag{3.7}$

The dissolution is allowed at all temperatures. This is the case of the metals of the IV group such as Ti, Zr, Hf.

- $\Delta H_{\text{ss}} < \Delta H_{\text{ox}} \tag{3.8}$

In this case Equation 3.6 is satisfied just if $T$ becomes high enough. So there is a threshold temperature for which the dissolution of the oxide
is allowed. This is the case of metals of the $V$ group such as $V$, $Nb$, $Ta$.

The concentration $x_0$ in the solid solution for which the oxide and the solid solution phase are in equilibrium and thus $\Delta G_{ss} = \Delta G_{ox}$, is called solubility limit. To take into account the reaction kinetics aspects in the pumping mechanism, the diffusivity has to be considered. Diffusion is a mass transport process which takes place when a concentration gradient exist between two points. The mass flux is mathematically described by the Fick’s law:

$$ \mathbf{J} = -D \nabla C $$

(3.9)

where $C$ is the concentration of the diffusing species and $D$ is the diffusion coefficient. $D$ is expressed in $[m/s^2]$ and is a function of the temperature $T$ of the system. $D$ is defined by the Arrhenius equation:

$$ D(T) = D_i e^{-\frac{E_i}{RT}} $$

(3.10)

being $D_i$ is the maximum diffusion coefficient and $E_i$ the activation energy for the diffusion of the element $i$.

By the diffusion coefficient it is possible to obtain another important quantity, namely the diffusion length, defined as the propagation distance in a certain direction after a time $t$ at temperature $T$.

$$ L = \sqrt{D(T)t} $$

(3.11)

Depending on the value of $L$ the diffusion process can occur at the grain boundaries or within the grains. If $L$ is lower than the grain dimension $\omega$ the diffusion will occur both at the grain boundaries and within the grain, otherwise the diffusion will take place mainly at the grain boundaries.
3.2 Getter technology for particle accelerator

For accelerators and storage rings built until the 70’s the vacuum needed was provided by mean of pumps connected to the vacuum chambers. This lumped pumping approach became very impractical with the new accelerator’s generation. The increase of the machine length, combined with the reduction of the diameter due to the increasing beam energy, led to the reduction of the chambers conductance. Therefore the employment of new pumping systems became essential, considering especially the degassing induced by synchrotron radiation. Integrated sputter-ion pumps were adopted in a first moment. These pumps used the magnetic field generated by the machine dipole magnets. However, in the case of LEP (Large Electron Positron Collider) the magnetic field at injection energy was too close to the pump ignition threshold, making the employment of this kind of pumps dangerous. Instead of sputter-ion pumps was then adopted a linear Non-Evaporable getter (NEG) pump, that doesn’t need a magnetic field to operate and provide an higher pumping speed. Linear NEG pump consisted of 30mm wide strips (St 101, SAES-Getters) coated on both sides with a 100μm thick layer of Non-Evaporable Getter of Zr$_{84}$Al$_{16}$ (weight percentage) powder [3]. These strips provided a pumping speed for $H_2$ of about 2000ℓ·s$^{-1}$m$^{-1}$; the ultimate pressure which they could produce was limited by the outgassing of $CH_4$ and Ar, $He$, noble gas and hydrocarbons in general, gases not pumped by NEG. A schematic of the LEP vacuum chamber cross-section is shown in Figure 3.1.

In order to be vacuum activated, the strips were heated until the activation temperature of 750°C by mean of a current of 90 A for about 30 minutes. The employment of a current for heating required electrical insulation for the strips, thus limiting the maximum achievable pumping speed. The use of new NEG alloys (St 707, SAES-Getters) requiring only one hour of activation at 400°C, makes layer passivation feasible during the usual bake-out of the vacuum system. Since the electrical insulation was not anymore required, it was possible to install a larger amount of NEG strips, thus providing higher pumping speed